

Supporting Information for

High Performance Rh₂P Electrocatalyst for Efficient Water Splitting

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Supplementary Figures

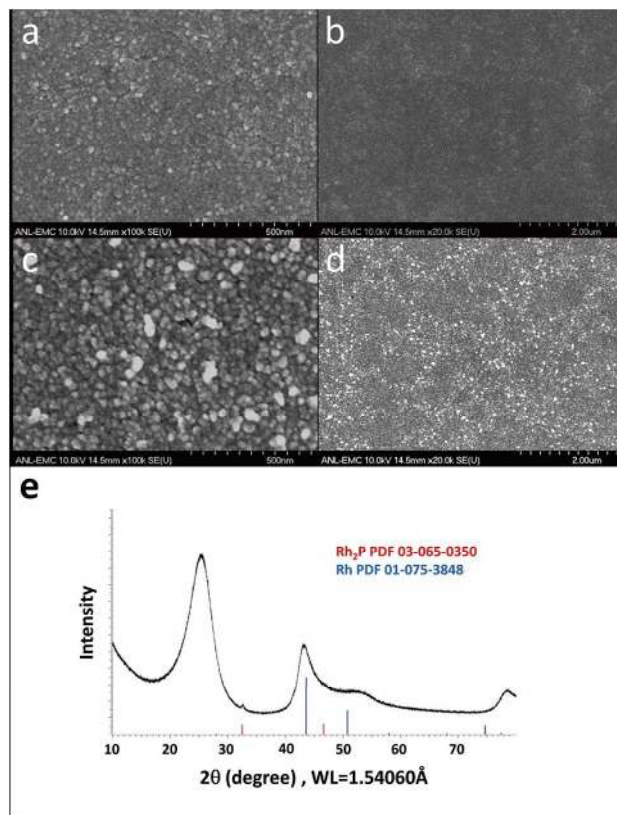


Figure S1. SEM images of the (a),(b) Rh and (c),(d) Rh₂P thin films. (e) XRD pattern of Rh₂P thin film.

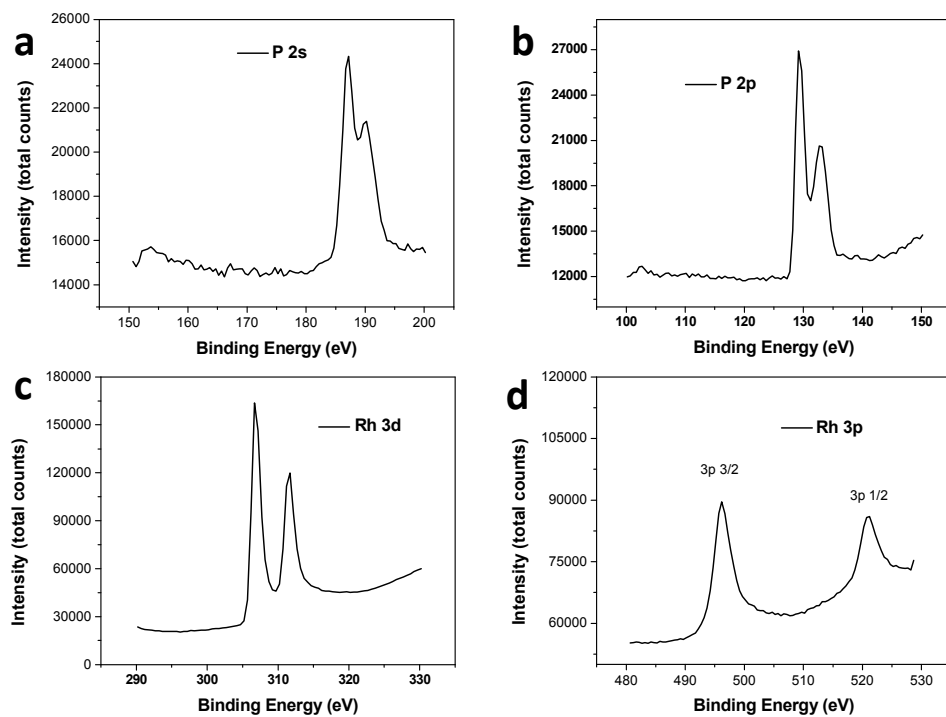


Figure S2. XPS spectra for Rh₂P thin films.* (a) Phosphorus 2s, 129.2 eV (Rh₂P), 132.7 eV (P oxide). (b) Phosphorus 2p, 187.2 eV (Rh₂P), 190.2 eV (P oxide). (c) Rhodium 3d, 306.7 eV (pure Rh), 311.7 eV (Rh₂P). (d) Rhodium 3p, 3p_{1/2}, 520.7 eV (Rh₂P), 3p_{3/2}, 496.2 eV (pure Rh). (*NIST X-ray Photoelectron Spectroscopy Database, NIST Standard Reference Database 20, Version 4.1 <https://srdata.nist.gov/xps/>)

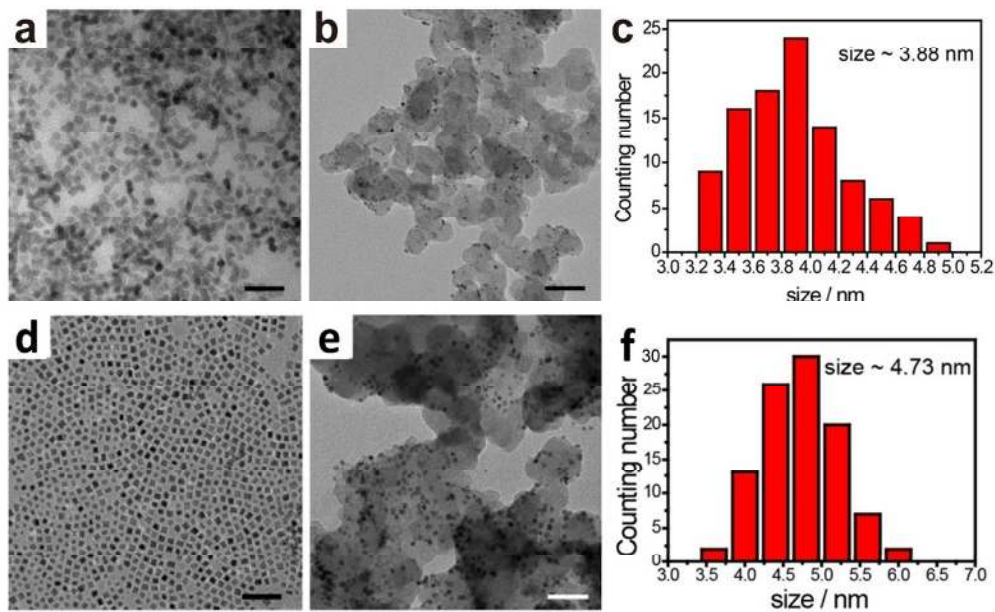


Figure S3. Characterizations of Rh NCs and Rh₂P NCs. (a-c) TEM images of as-synthesized Rh NCs (scale bar, 20 nm), Rh NCs supported on Vulcan XC-72 carbon (scale bar, 50 nm) and size distribution of Rh NCs, respectively. (d-f) TEM images of as-synthesized Rh₂P NCs, Rh₂P NCs supported on Vulcan XC-72 carbon and size distribution of Rh₂P NCs, respectively. Scale bar equals 50 nm.

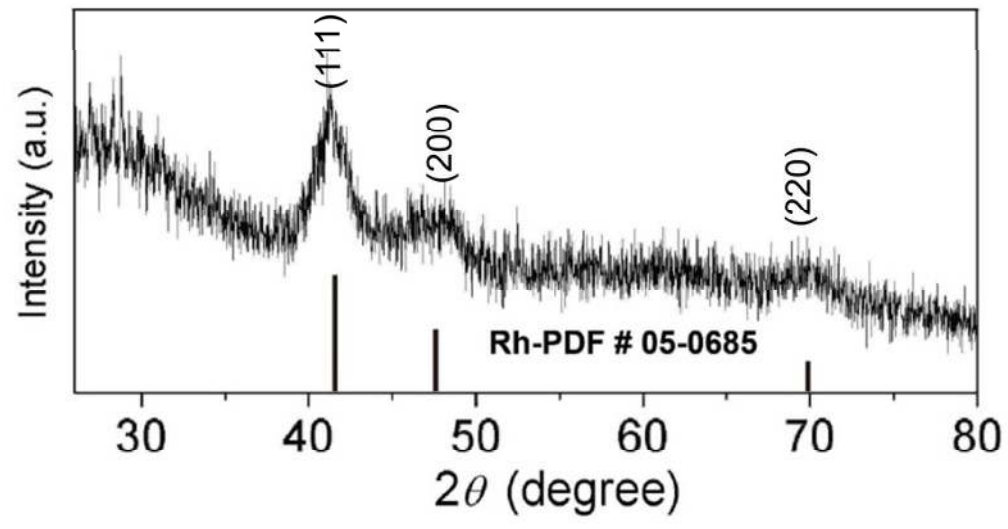


Figure S4. XRD pattern of Rh NCs. XRD pattern of Rh NCs (up) and metallic Rh (bottom, JCPDS: 05-0685).

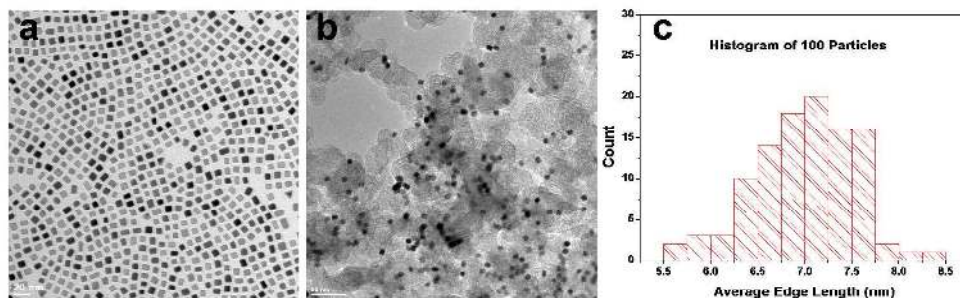


Figure S5. (a) TEM image of as-synthesized Pt nanocubes. Scale bar equals 20 nm. (b) TEM image of Pt nanocubes loaded on Vulcan XC-72 carbon after annealing at 185 °C in air. Scale bar equals 50 nm. (c) Histogram of particle size distribution counted from 100 particles. Average particle edge length is $7.0 \text{ nm} \pm 0.6 \text{ nm}$.

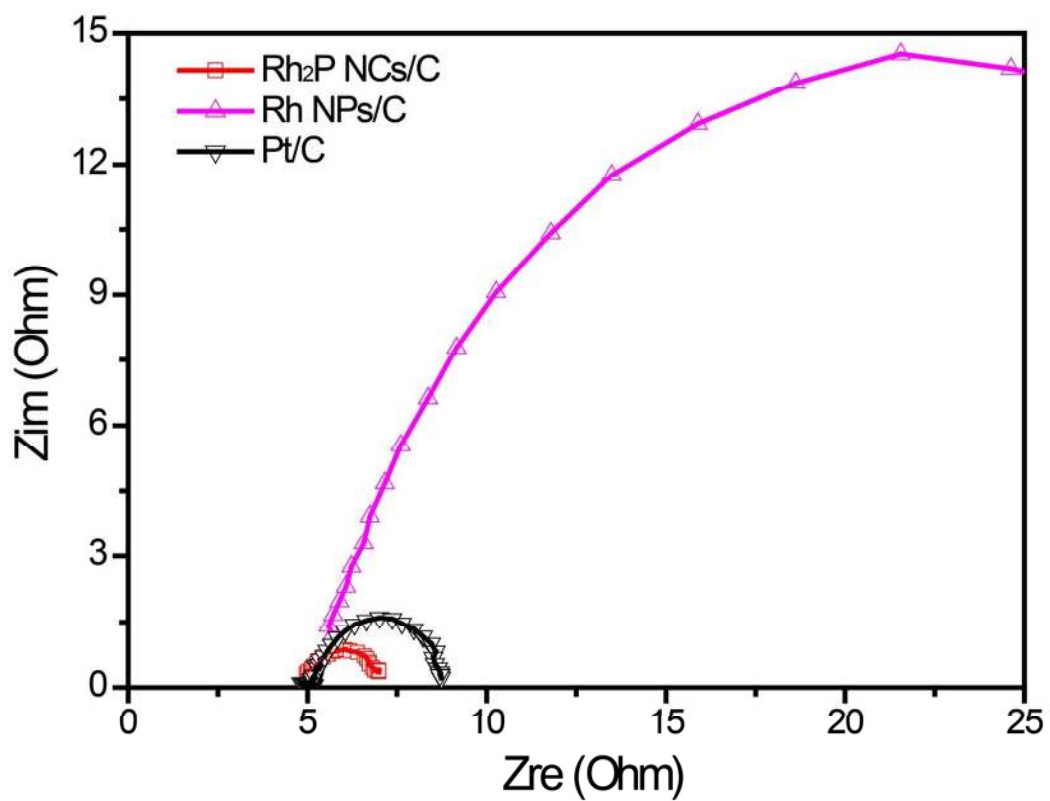


Figure S6. Nyquist plots of comparing catalysts. Nyquist plots under $\eta = 3.8$ mV.

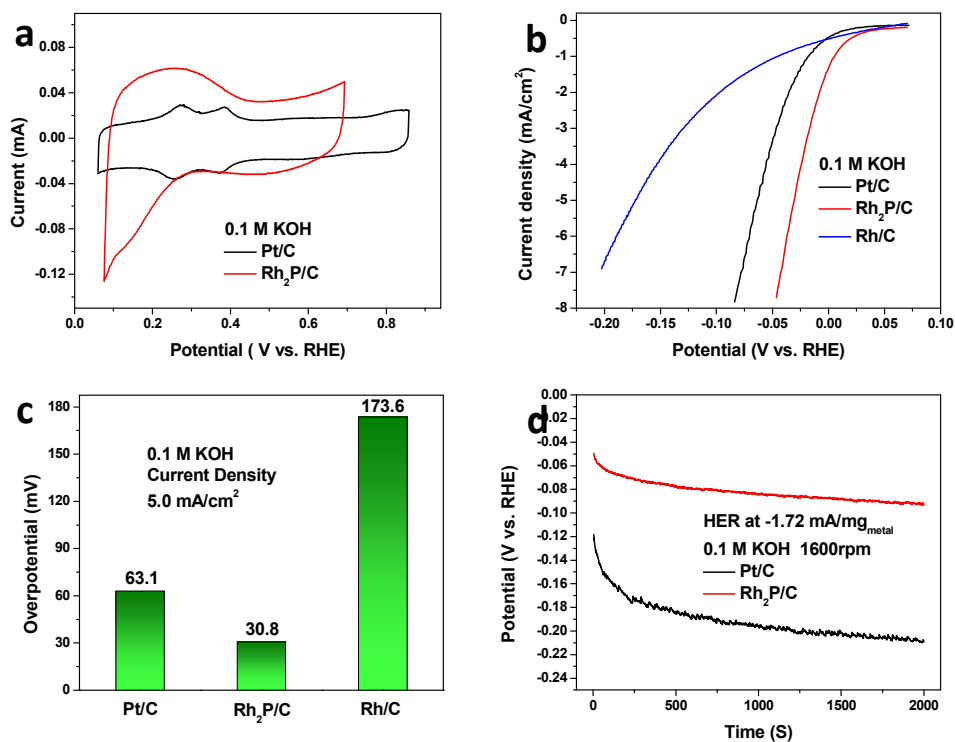


Figure S7. Hydrogen evolution reaction properties in alkaline media (0.1 M KOH). (a) Cyclic voltammograms of Rh₂P/C and Pt/C. (b) Polarization curves for Pt/C (3.7 $\mu\text{g}_{\text{Pt}}/\text{cm}^2$), Rh₂P/C (3.7 $\mu\text{g}_{\text{Rh}}/\text{cm}^2$) and Rh/C (13.3 $\mu\text{g}_{\text{Rh}}/\text{cm}^2$) recorded at 20 mV/s and (c) Corresponding overpotentials at 5.0 mA/cm² current density. (d) Chronopotentiometry of the Rh₂P/C and Pt/C recorded at -1.72 mA/mg_{metal} current density. The potentials were converted to RHE and corrected for iR drop.

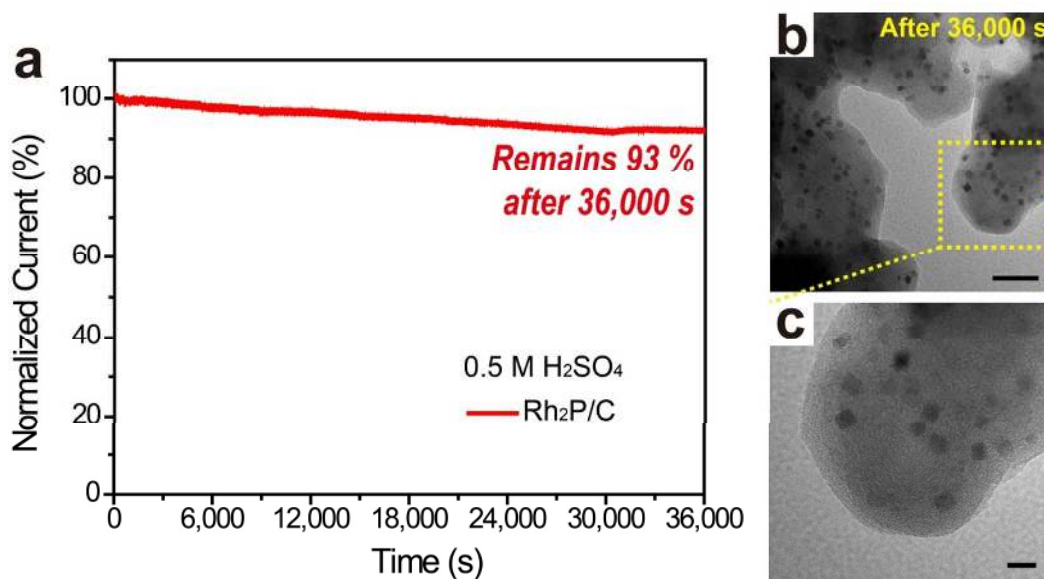


Figure S8. Durability performance of the Rh₂P catalyst. (a) Chronoamperometry for Rh₂P/C under overpotential $\eta = 109$ mV for 36,000 s, showing electrochemical durability under acidic conditions (0.5 M H₂SO₄). (b) Low-magnification (scale bar, 40 nm) and (c) high-magnification (scale bar, 10 nm) TEM images of Rh₂P/C after electrolysis for 36,000 s.

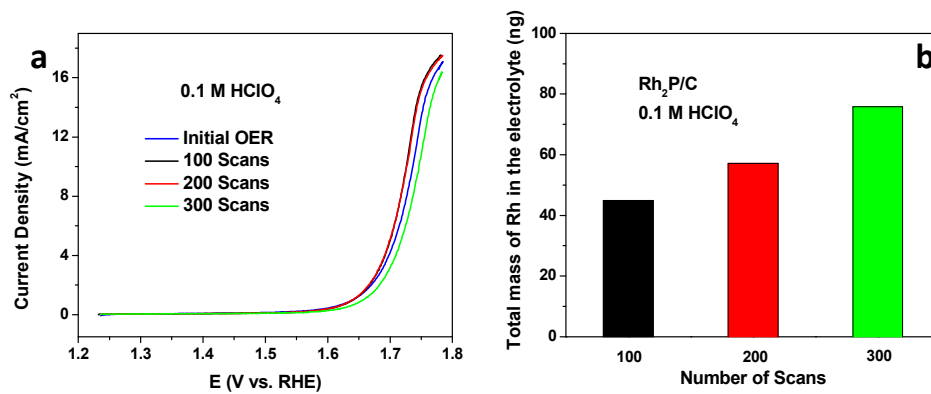


Figure S9. $\text{Rh}_2\text{P/C}$ OER stability under potential cycling. (a) Polarization curves for $\text{Rh}_2\text{P/C}$ recorded at 20 mV/s, 1600 rpm, 0.1 M perchloric acid. (b) Total mass of Rh (nanograms) in the electrolyte from ICP analysis. The potential cycling was between 1.23 V and 1.78 V, at the scan rate of 50 mV/s.

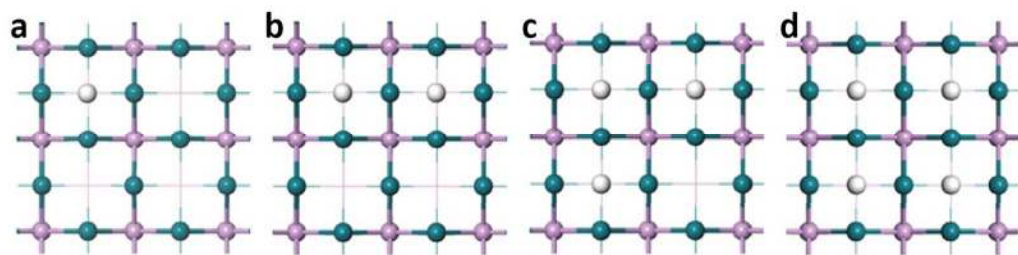


Figure S10. Optimized structures of H adsorption with different coverage on Rh-terminated surface.

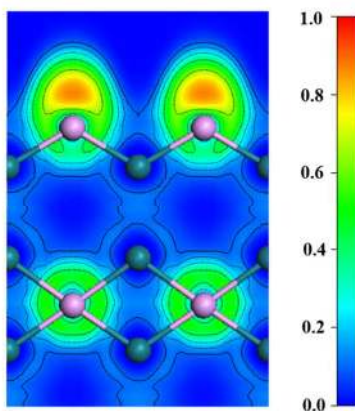


Figure S11. Calculated electron localization function (ELF) of the Rh₂P (200) surface.

The calculated ELF value ranges from 0.0 (blue) to 1.0 (red).

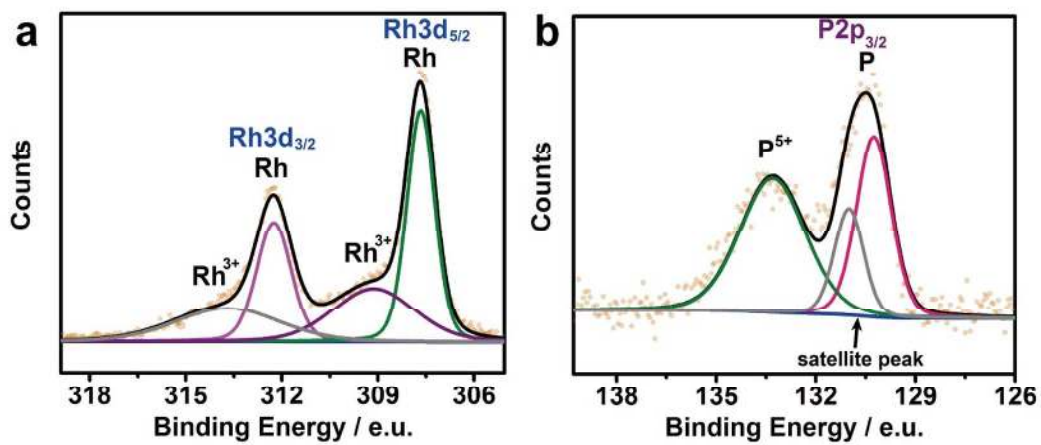


Figure S12. XPS spectra for Rh₂P/C. XPS spectra in the (a) Rh(3d) regions and (b) P(2p) region of AA washed Rh₂P/C.

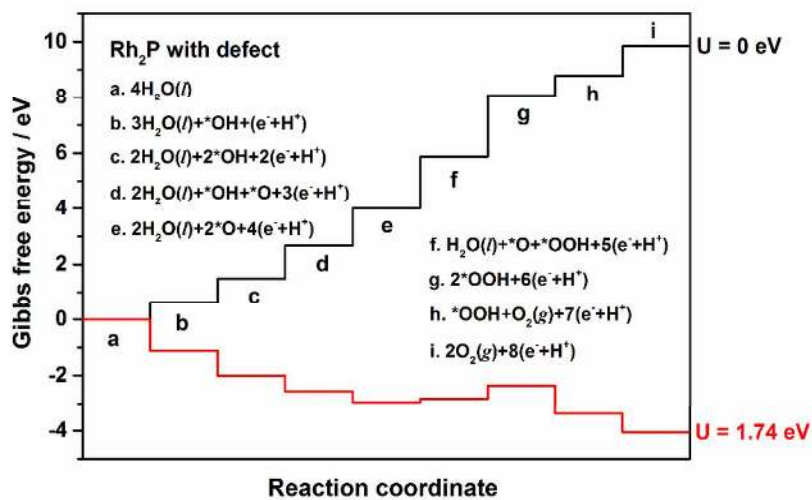


Figure S13. Gibbs free energy profiles. The calculated Gibbs free energy profiles of the intermediate states in OER on Rh₂P (200)-defect surface.

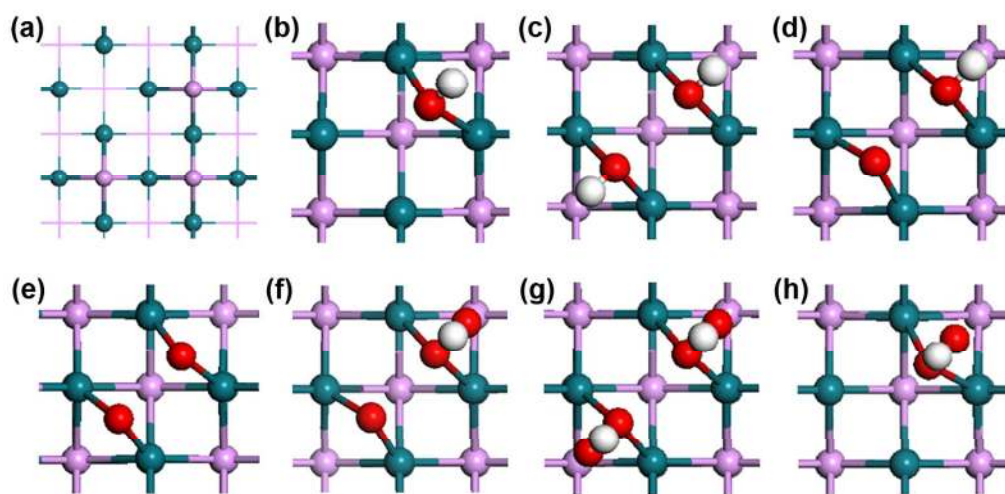


Figure S14. Optimized structures of the intermediate states in OER on Rh₂P (200)-defect surface. (a) Optimized structures of the Rh₂P (200) surface with defect. (b-h) Optimized structures of the intermediate states in OER on Rh₂P (200)-defect surface.

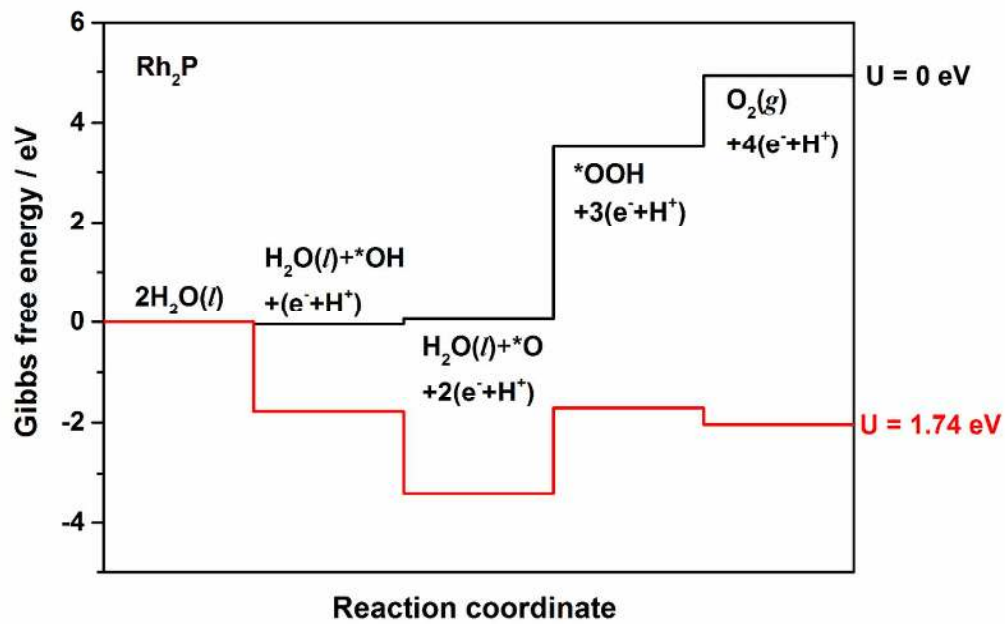


Figure S15. Gibbs free energy profiles. The calculated Gibbs free energies (eV) profiles of the intermediate states in OER on Rh_2P (200) surface.

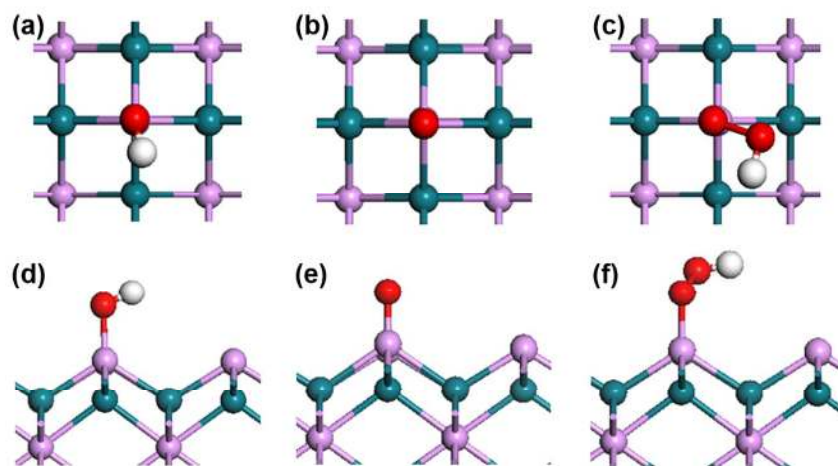


Figure S16. Optimized structures of the intermediate states in OER on Rh₂P (200) surface. (a) and (d) are the top view and side view of the *OH; (b) and (e) are the top view and side view of the *O; (c) and (f) are the top view and side view of the *OOH.

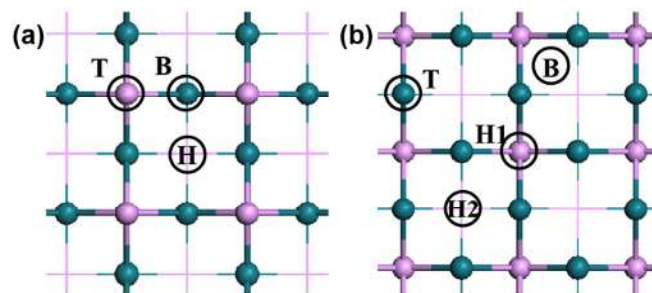


Figure S17. Binding sites of H atom. The binding sites for H adsorption on the top view of (a) P-terminated and (b) Rh-terminated Rh_2P (200) surfaces.

Supplementary Tables

Table S1. ICP-AES analysis.

Materials	Rh ($\mu\text{g/mL}$)	P ($\mu\text{g/mL}$)	Rh / P (mmol/mmol)
Rh ₂ P NCs/C (not treated by AA)	136.7	24.9	1.65
Rh ₂ P NCs ¹ /C	132.9	18.6	2.15

¹The materials were washed with AA by using method described in experimental section.

Table S2. Calculated adsorption energies and Gibbs free energies of H adsorption on Rh₂P (200) surfaces.

H coverage	P-terminated		Rh-terminated	
	ΔE_{H} (eV)	$\Delta G^{\circ}_{\text{H}}$ (eV)	ΔE_{H} (eV)	$\Delta G^{\circ}_{\text{H}}$ (eV)
1/4 ML	-0.08	0.15	-0.58	-0.51
2/4 ML	-0.25	0.00	-0.66	-0.51
3/4 ML	-0.05	0.18	-0.84	-0.66
4/4 ML	-0.06	0.17	-0.90	-0.75

Table S3. Calculated Free Energies of Reaction Steps in OER on Rh₂P (200)-defect Surface.

steps	ΔE	$\Delta_{0 \rightarrow 298K} \Delta H^{ab}$	ΔZPE	$-T\Delta S^{bc}$	$- e U$	ΔG
H ₂ O → *OH+e ⁻ +H ⁺	0.29	-0.06	-0.08	0.47	-1.74	-1.12
H ₂ O → *OH+e ⁻ +H ⁺	0.50	-0.06	-0.06	0.47	-1.74	-0.89
*OH → *O+e ⁻ +H ⁺	1.52	0.04	-0.17	-0.2	-1.74	-0.55
*OH → *O+e ⁻ +H ⁺	1.67	0.04	-0.18	-0.2	-1.74	-0.41
H ₂ O+*O → *OOH+e ⁻ +H ⁺	1.52	-0.06	-0.06	0.47	-1.74	0.13
H ₂ O+*O → *OOH+e ⁻ +H ⁺	1.87	-0.06	-0.08	0.47	-1.74	0.47
*OOH → O ₂ +e ⁻ +H ⁺	1.61	0.13	-0.21	-0.83	-1.74	-1.03
*OOH → O ₂ +e ⁻ +H ⁺	1.95	0.13	-0.19	-0.83	-1.74	-0.68

- a. $\Delta_{0 \rightarrow 298K} \Delta H$ denotes the correction of ΔH from 0K to 298K.
- b. These data were cited from D.R. Stull, H. Propser, JANAF Thermochemical Tables, U. S. National Bureau of Standards, Washington, DC, 1971.
- c. The value of $T\Delta S$ (H₂O) includes the correction of ΔG (H₂O) from gas to liquid.

Table S4. Calculated Free Energies of Reaction Steps in OER on Rh₂P (200) Surface.

steps	ΔE	$\Delta_{0 \rightarrow 298K} \Delta H$	ΔZPE	$-T\Delta S$	$- e U$	ΔG
$H_2O \rightarrow *OH + e^- + H^+$	-0.36	-0.06	-0.09	0.47	-1.74	-1.78
$*OH \rightarrow O^* + e^- + H^+$	0.39	0.04	-0.13	-0.2	-1.74	-1.64
$H_2O + *O \rightarrow *OOH + e^- + H^+$	3.14	-0.06	-0.10	0.47	-1.74	1.71
$*OOH \rightarrow O_2 + e^- + H^+$	3.46	0.14	-0.19	-0.83	-1.74	-0.33

Table S5. Calculated binding energies (eV) of one H atom on Rh₂P (200) surfaces

Binding site	Binding energy (eV)	
	P-terminated	Rh-terminated
top (T)	-0.07	-0.21
bridge (B)	0.63	-b
hollow1 (H1)	0.78 ^a	-c
hollow2 (H2)	0.78 ^a	-0.58

a For P-terminated Rh₂P (200) surface, hollow1 and hollow2 site are the same

b The adsorption on the bridge site is unstable and the H atom moves to the hollow2 site

c The adsorption on the hollow1 site is unstable and the H atom moves to the hollow2 site